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## TOTAL IONIZATION DOSE TEST REPORT

No. 99T-RT1020-159

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### 1.0 SUMMARY TABLE

RT1020 Parameters/Characteristics	Results
1. Functionality	>> 100 krad(Si)
2. $I_{DDSTDBY}$	Passed 100 krad(Si) (see Figure 2)
3. $V_{IL}/V_{IH}$	Passed 100 krad(Si) (see Table 5)
4. $V_{OL}/V_{OH}$	Passed 100 krad(Si) (see Figures 3-8)
5. Propagation Delays	Passed 100 krad(Si) (see Table 6,7)
6. Rising/Falling Edge Transient	Passed 100 krad(Si) (see Figures 9-18)
7. Power-on Transient Current	Passed 100 krad(Si) (see Figures 19-22)

### 2.0 TID TEST

This section describes the device under test (DUT), the irradiation parameters, and the testing method.

#### 2.1 TEST DEVICE

Table 1 lists the DUT information.

Table 1

Part Number	RT1020
Package	CQ84
Foundry	LMSEC
Technology	0.8 $\mu$ m CMOS
Die Lot Number	970159
Date Code	9839
Quantity Tested	5
Serial Numbers	Control (LAN1705), LAN1701, LAN1702, LAN1703, LAN1704

#### 2.2 IRRADIATION

Table 2 lists the irradiation parameters.

Table 2

Facility	NASA
Radiation Source	Co-60
Dose Rate	12.95 krad(Si)/min (+-10%)
Final Total Dose for DC/AC Parameter Measurement	100 krad(Si)
Temperature	Room
Bias	5.0 V

### **2.3 TESTING METHOD**

The testing method is following the spirit of TM1019.5 and targets for the low-dose-rate space applications. Figure 1 shows the flow. Room temperature annealing and post annealing tests were omitted in this testing because the DUTs showed no radiation effects after 100 krad(Si) (e.g.  $I_{DDSTDY}$  in Figure 2 was constant throughout the irradiation). Rebound annealing is also omitted because there are enough data showing Actel antifuse FPGA not having any adverse rebound effects.

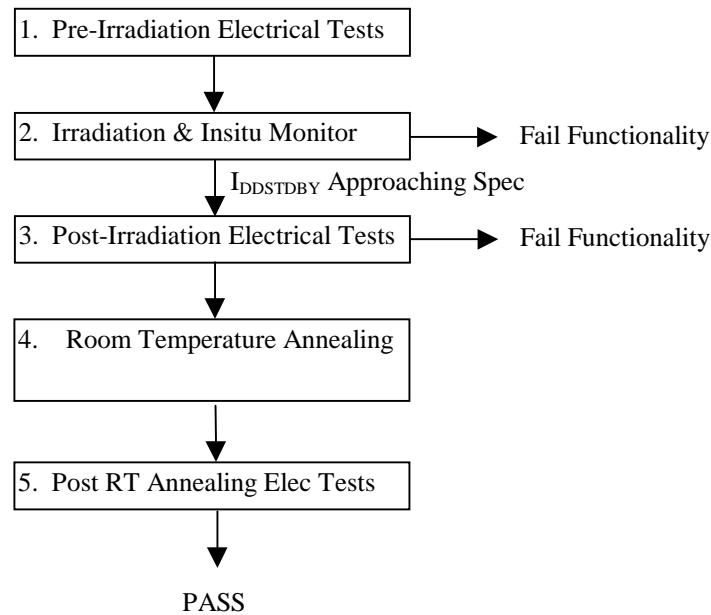


Figure 1. Test method flow-chart

### **2.4 ELECTRICAL PARAMETERS/CHARACTERISTICS TESTS**

The electrical parameters/characteristics were measured on bench with relative low noise. The corresponding logic design circuits are listed in Table 3.

Table 3

Parameter/Characteristics	Logic Design
1. Functionality	All key architectural functions
2. $I_{DDSTDY}$	DUT power line
3. $V_{IL}/V_{IH}$	TTL compatible input buffer
4. $V_{OL}/V_{OH}$	Output buffer
5. Propagation Delays	String of inverters
6. Rising/Falling Edge	D flip-flop output
7. Power-on Transient	DUT power line

### **3.0 TEST RESULTS**

This section presents all the parameters/characteristics results for pre-irradiation (step 1 in Figure 1), post-irradiation (step 3).

### **3.1 FUNCTIONAL TEST**

Two types of functionality tests were performed. Samples were irradiated until functional failure occurred to determine the functionality tolerance in the summary table. The second type is including in the testing flow (Figure 1). Each test step (step 1, 3) has a functional test by default. Table 4 lists the second testing results of all five DUTs.

Table 4. Functionality Test

	Pre-Irradiation	Post-100krad (Si) Irradiation
Cntl (LAN1705)	passed	passed
LAN1701	passed	passed
LAN1702	passed	passed
LAN1703	passed	passed
LAN1704	passed	passed

### **3.2 IDDSTANDBY**

$I_{DD\text{standby}}$  and functionality of four pins were monitored during the irradiation period. Because the board had a measurable leakage, only the delta  $I_{DD\text{standby}}$  due to radiation was recorded. Using delta  $I_{DD\text{standby}}$ , won't create any significant extraneous error since the pre-irradiation value of  $I_{DD\text{standby}}$  is under 1 mA. The increment of  $I_{DD\text{standby}}$  by irradiation determines the tolerance. Although only two DUTs are shown in Figure 2, all the irradiated DUTs showed no increase in standby current throughout the irradiation.

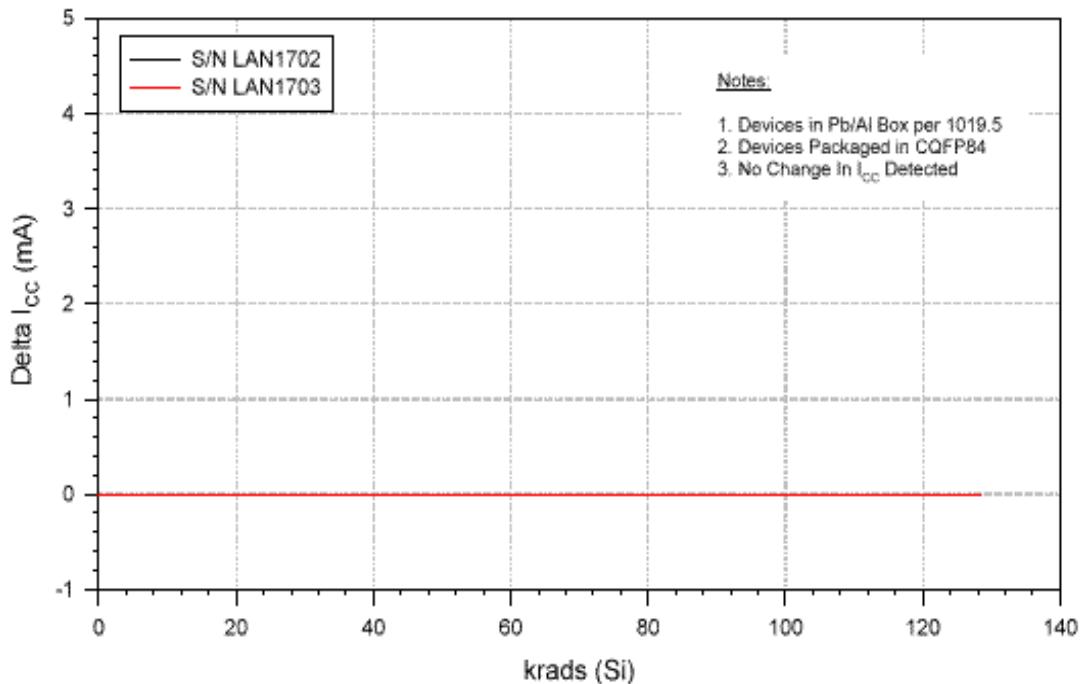


Figure 2. Delta  $I_{DD\text{standby}}$  versus total cumulative dose

### **3.3 INPUT LOGIC THRESHOLD**

The testing result of the input logic threshold ( $V_{IL}/V_{IH}$ ) is listed in Table 5.

Table 5. Input Logic ( $V_{IL}/V_{IH}$ ) Threshold (Volts)

	Pre-Irradiation	Post-100krad(Si) Irradiation
Cntl (LAN1705)	1.71	1.74
LAN1701	1.72	1.72
LAN1702	1.71	1.71
LAN1703	1.72	1.64
LAN1704	1.72	1.64

### 3.4 OUTPUT I-V CHARACTERISTICS

Figures 3 and 4 display the radiation effects on output ( $V_{OL}/V_{OH}$ ) characteristics (I-V curves). Only the post 100 krad(Si) data are shown with the control data. There are no radiation effects on these characteristics.

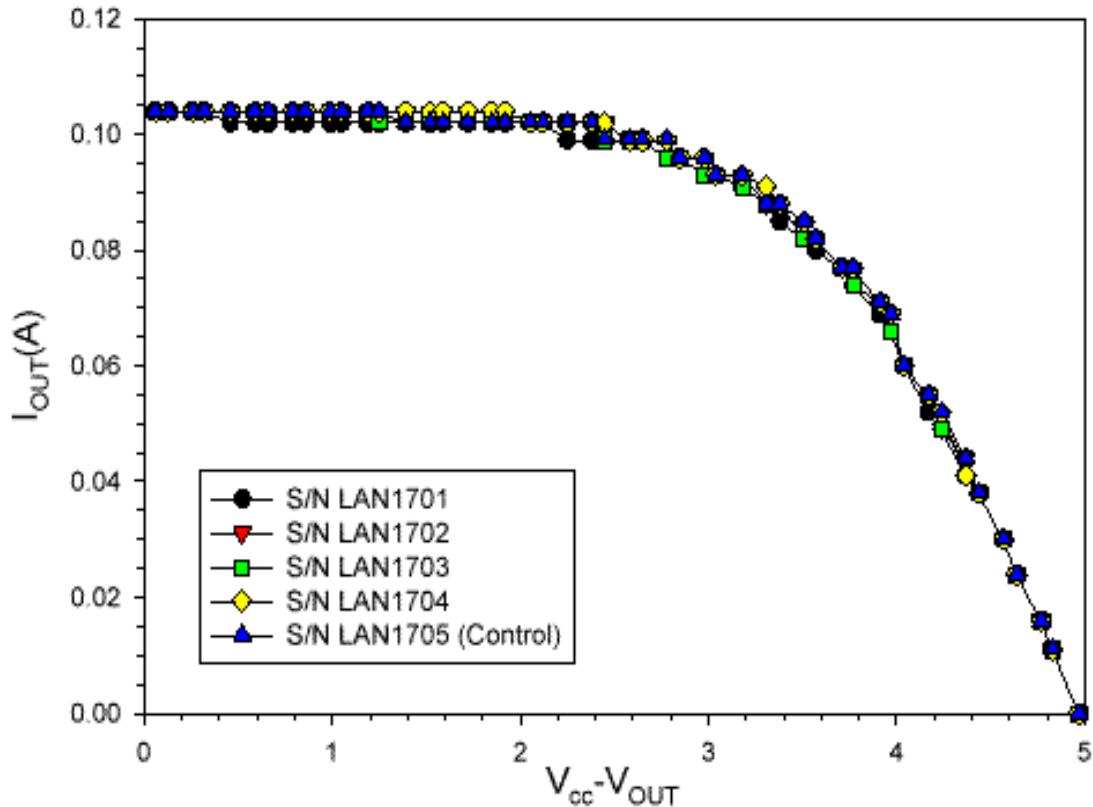


Figure 3. Post 100 krad(Si) irradiation  $V_{OL}$  I-V

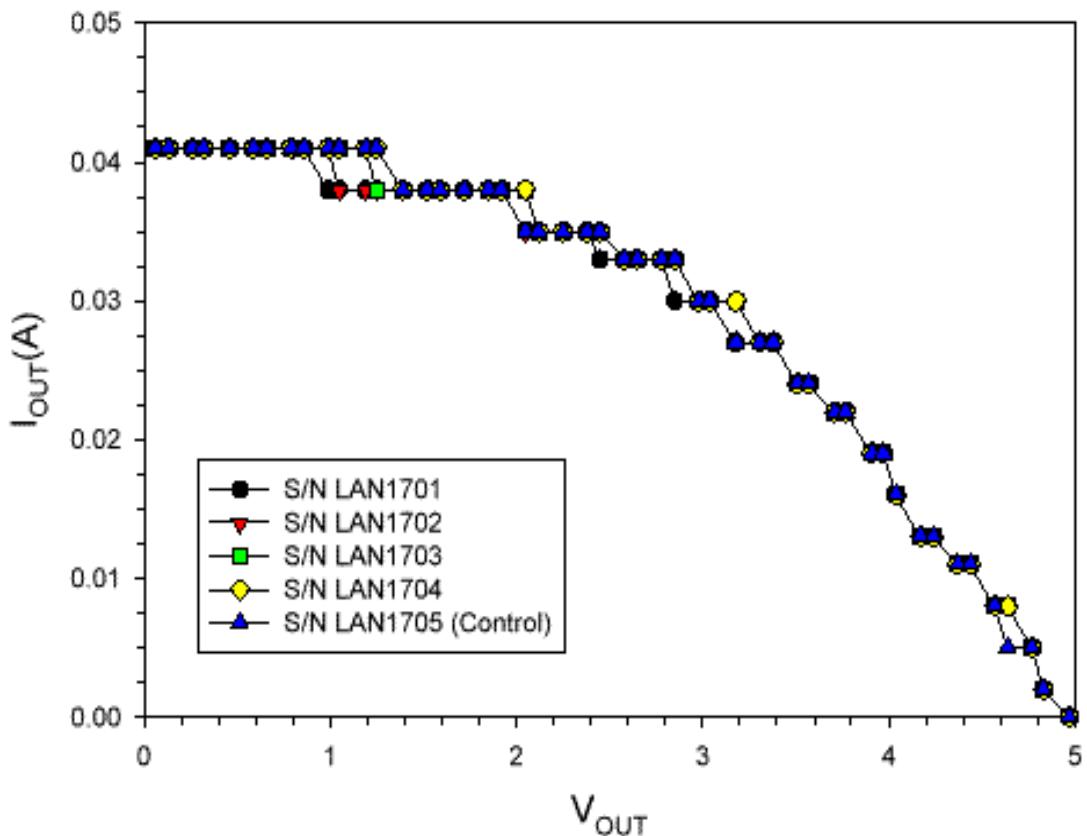


Figure 4. Post-100 krad(Si) irradiation  $V_{OH}$  I-V

### 3.5 PROPAGATION DELAYS

Rising and falling edge delays are shown in Table 6 and 7 respectively.

Table 6. Rising Edge Propagation Delays (ns)

	Pre-Irradiation	Post-100krad(Si) Irradiation
Cntl (LAN1705)	260	259
LAN1701	269	265
LAN1702	261	259
LAN1703	264	262
LAN1704	261	259

Table 7. Falling Edge Propagation Delays (ns)

	Pre-Irradiation	Post-100krad(Si) Irradiation
Cntl (LAN1705)	232	232
LAN1701	235	241
LAN1702	231	238
LAN1703	230	236
LAN1704	229	235

### **3.6 RISING/FALLING EDGE TRANSIENT**

The 100 krad(Si) total dose effects on the rising and falling edge transient characteristics were measured on a D flip-flop. Figures 5-8 show the rising edge of the DUTs. Figures 9-12 show the falling edge. No significant radiation effects can be detected in any case.

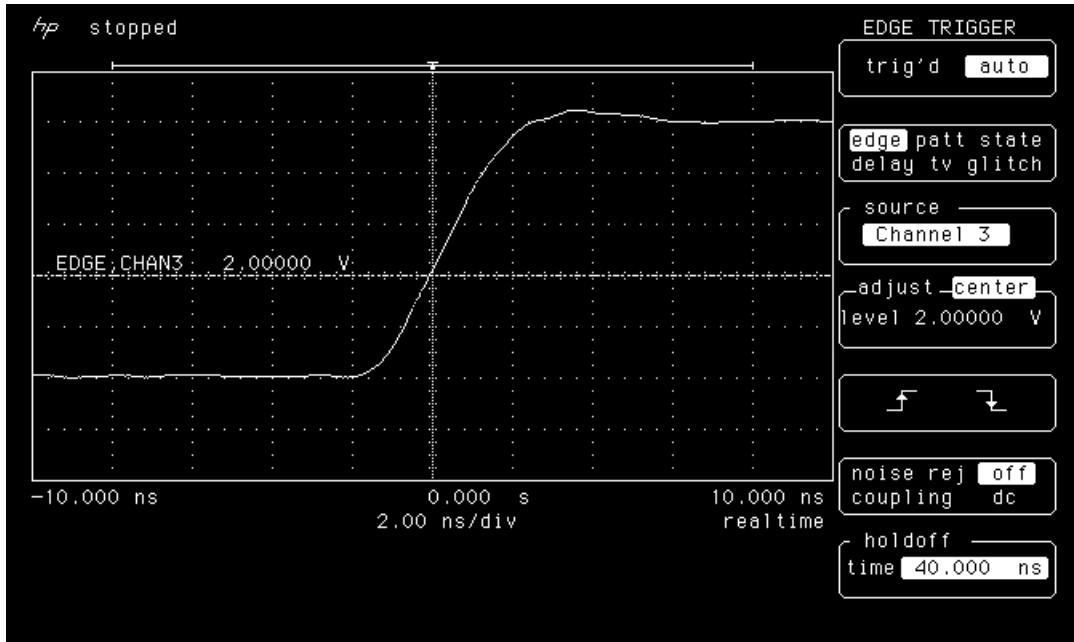


Figure 5a. Rising edge of LAN1701 pre-irradiation

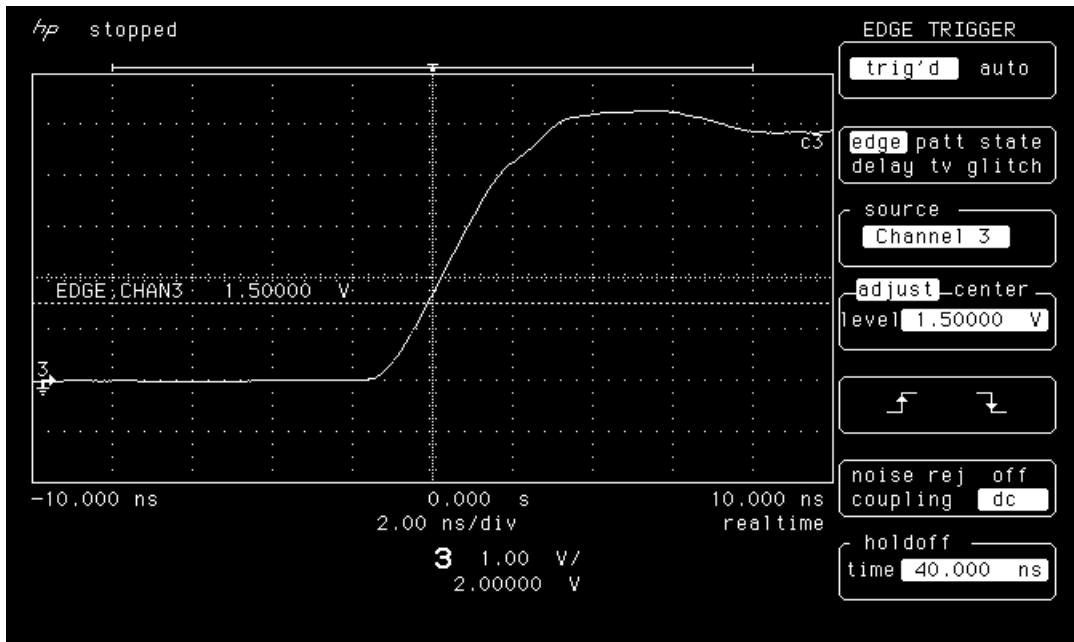


Figure 5b. Rising edge of LAN1701 post-100 krad(Si) irradiation

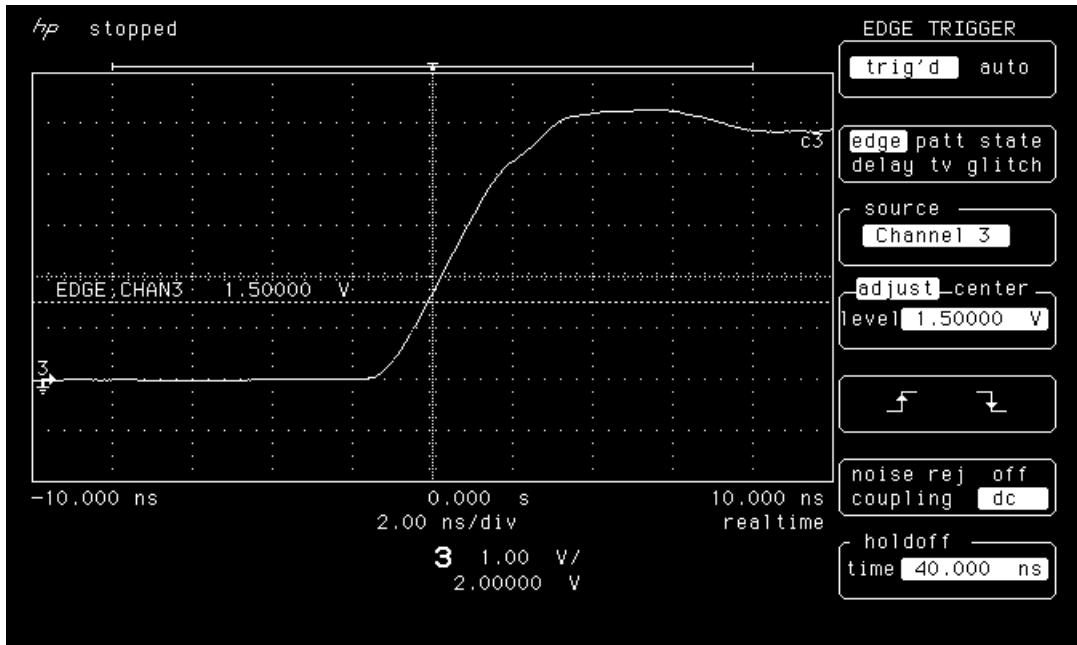


Figure 6a. Rising edge of LAN1702 pre-irradiation

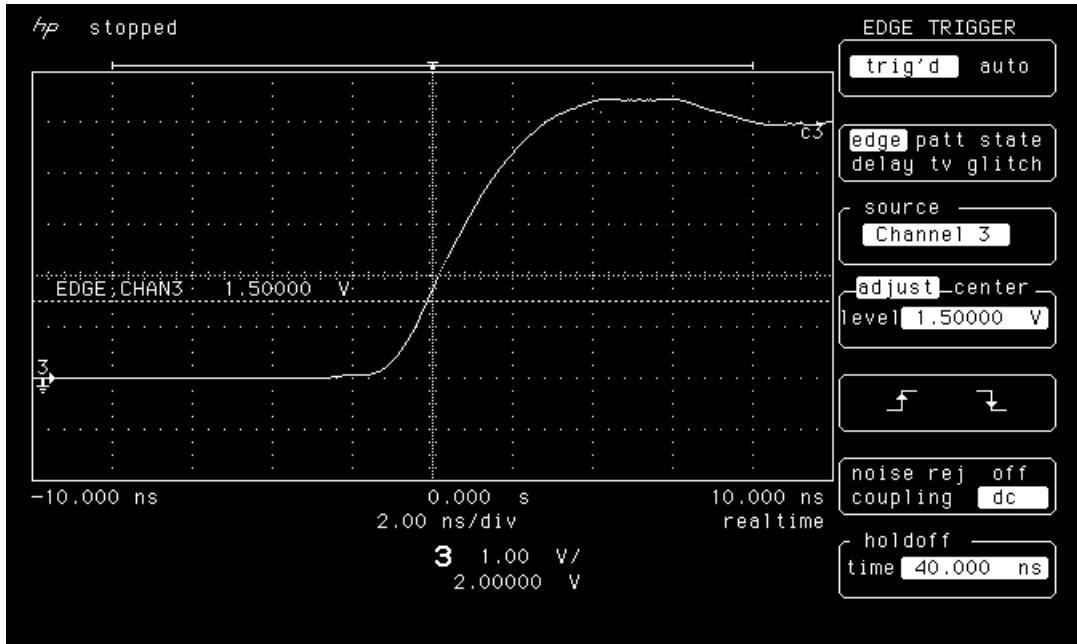


Figure 6b. Rising edge of LAN1702 post 100 krad(Si) irradiation

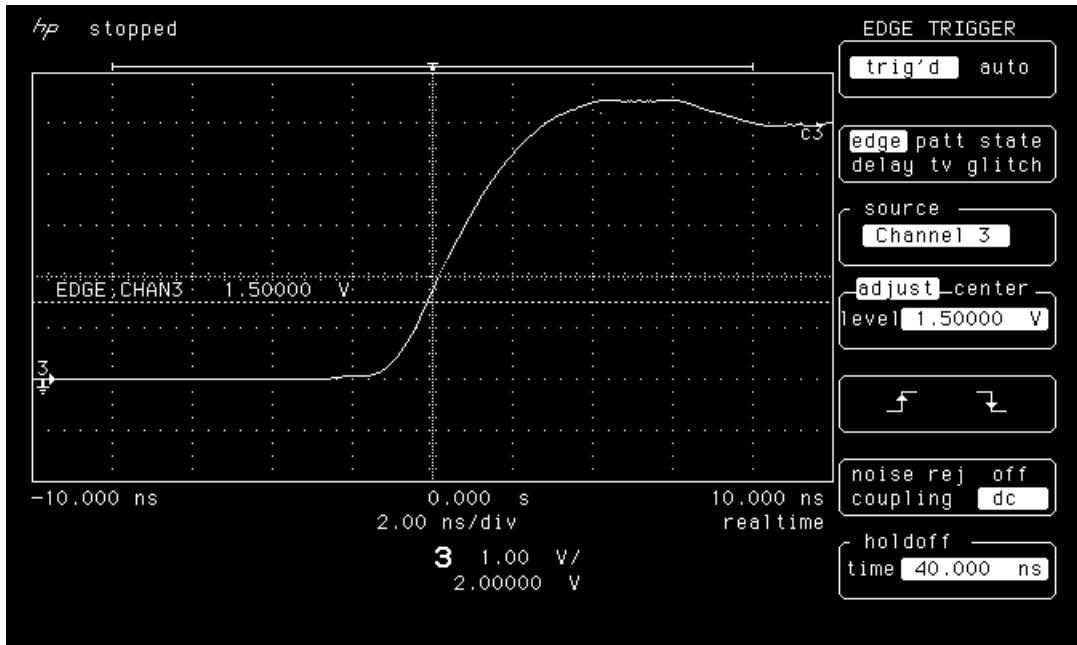


Figure 7a. Rising edge of LAN1703 pre-irradiation

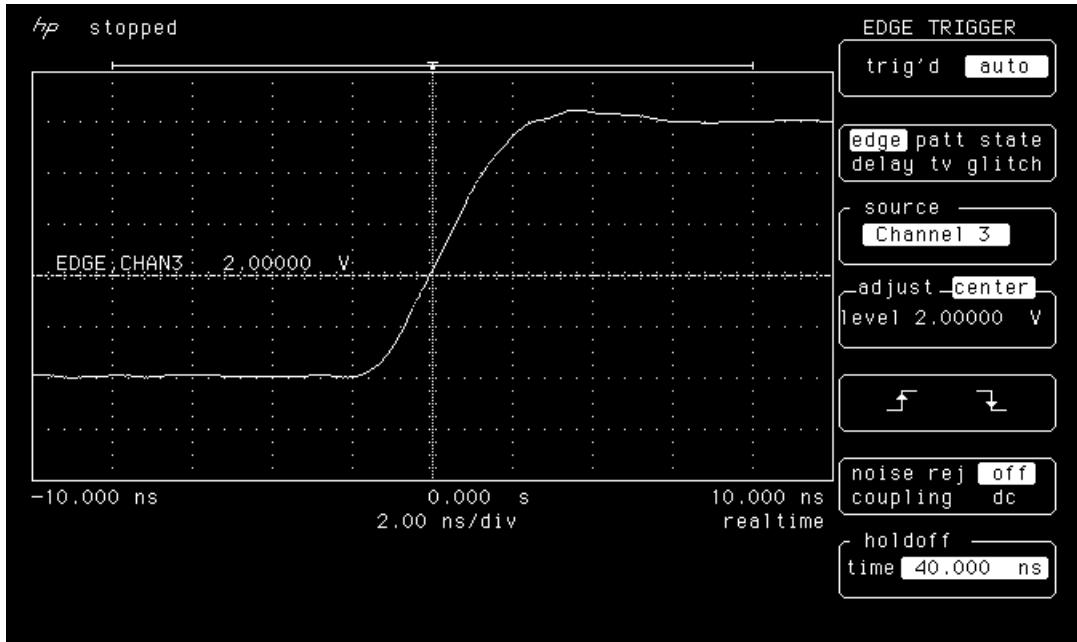


Figure 7b. Rising edge of LAN1703 post 100 krad(Si) irradiation

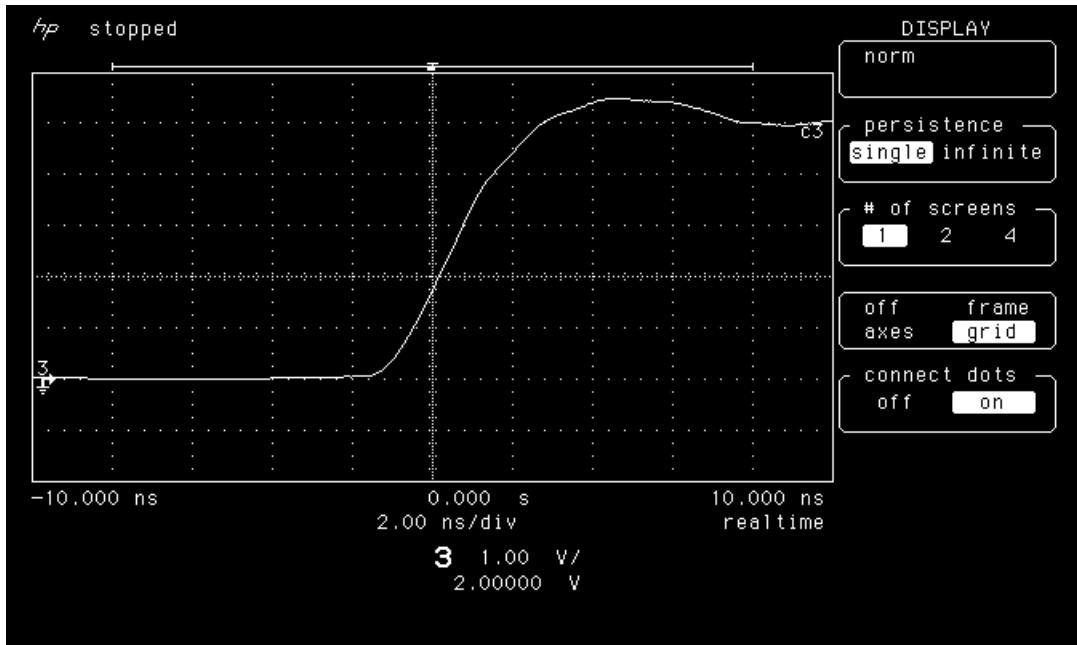


Figure 8a. Rising edge of LAN1704 pre-irradiation

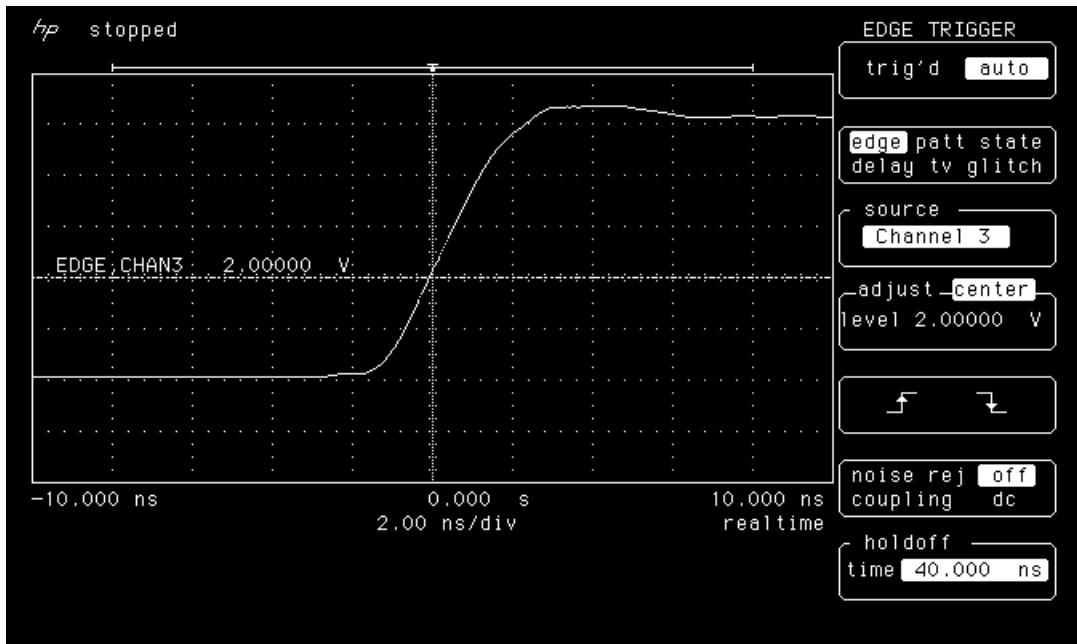


Figure 8b. Rising edge of LAN1704 post-100 krad(Si) irradiation

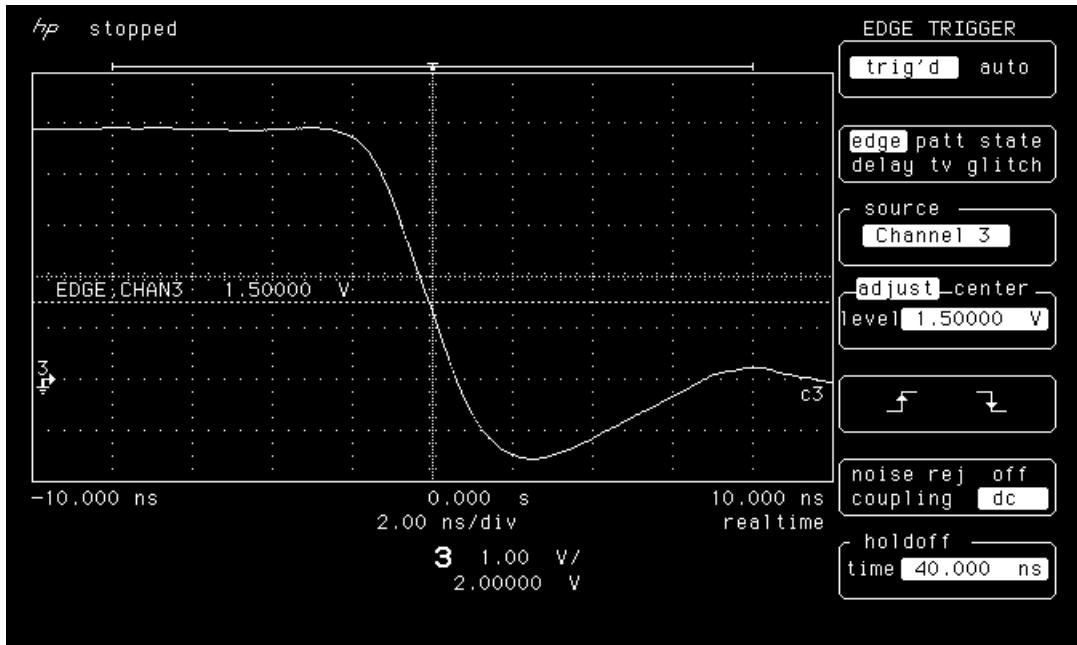


Figure 9a. Falling edge of LAN1701 pre-irradiation

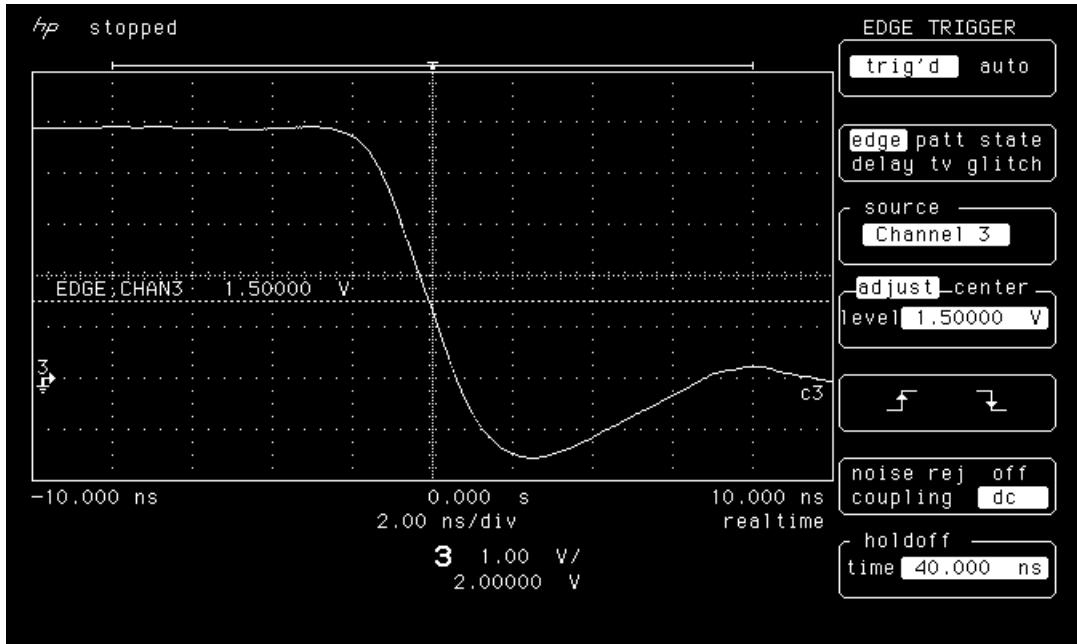


Figure 9b. Falling edge of LAN1701 post-100 krad(Si) irradiation

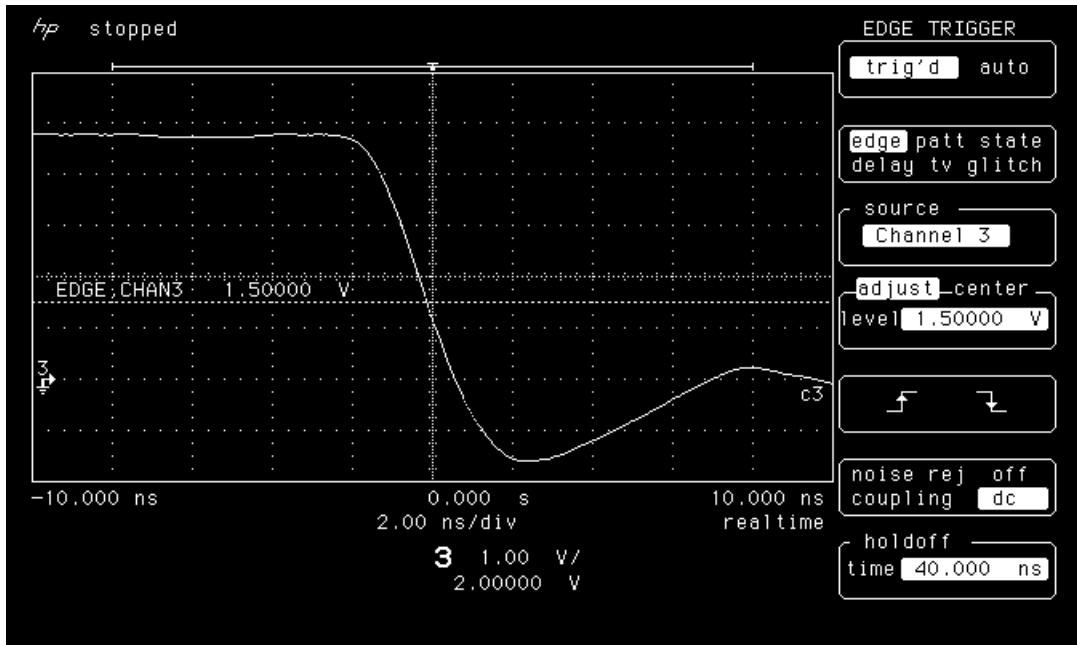


Figure 10a. Falling edge of LAN1702 pre-irradiation

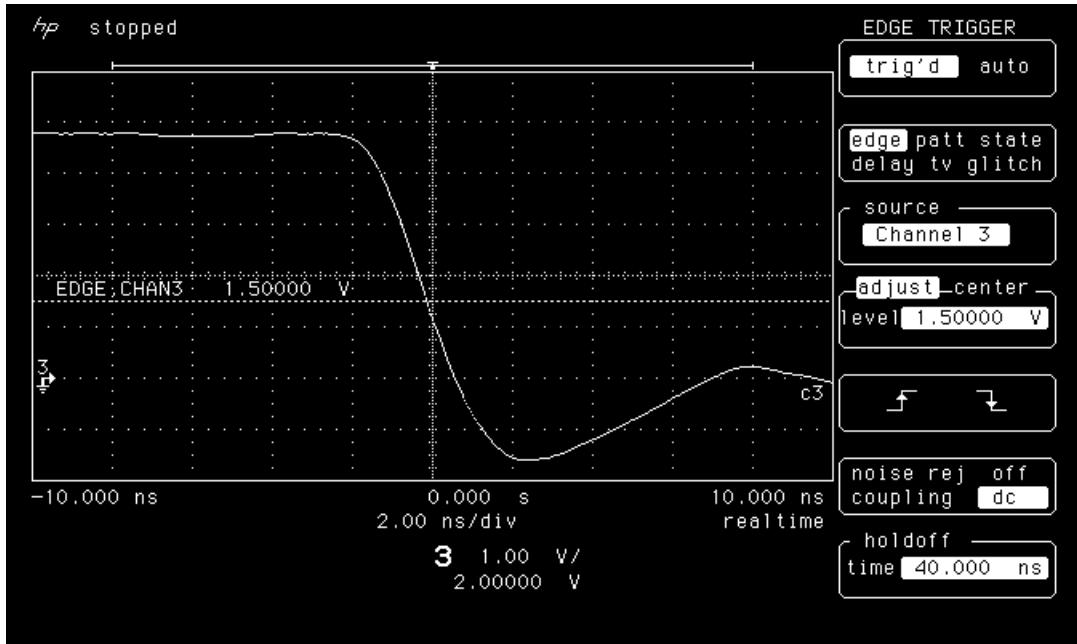


Figure 10b. Falling edge of LAN1702 post-100 krad(Si) irradiation

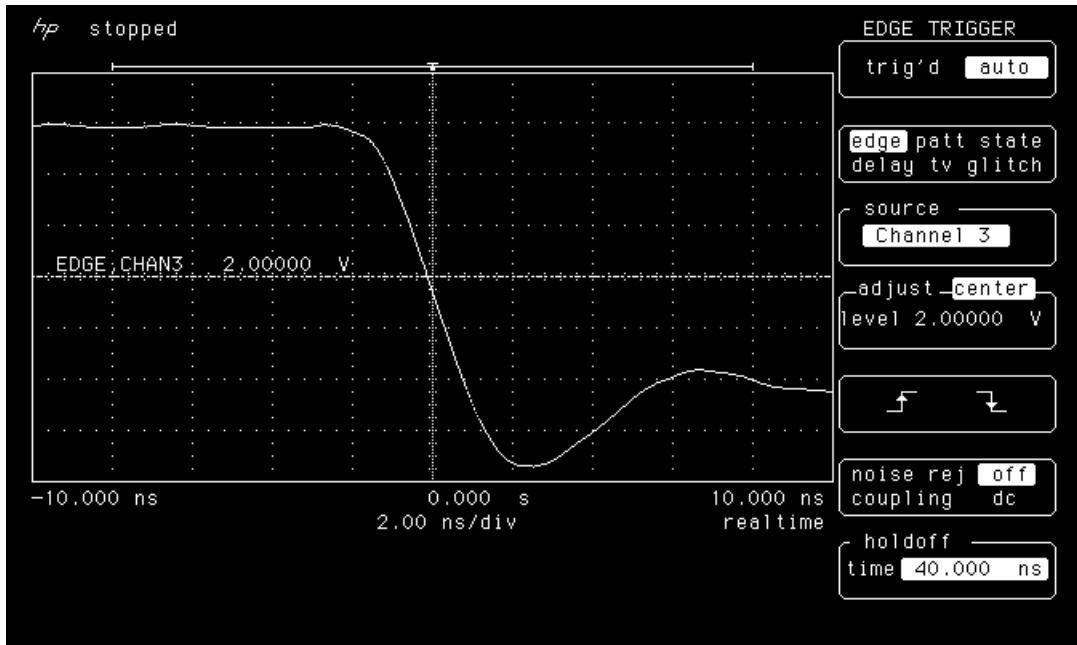


Figure 11a. Falling edge of LAN1703 pre-irradiation

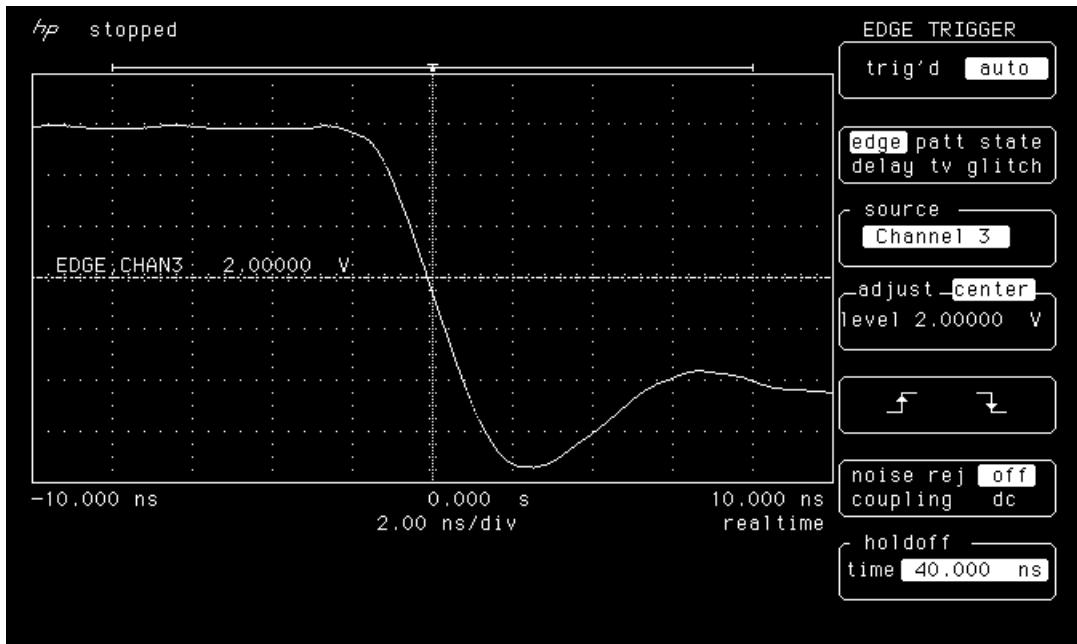


Figure 11b. Falling edge of LAN1703 post-100 krad(Si) irradiation

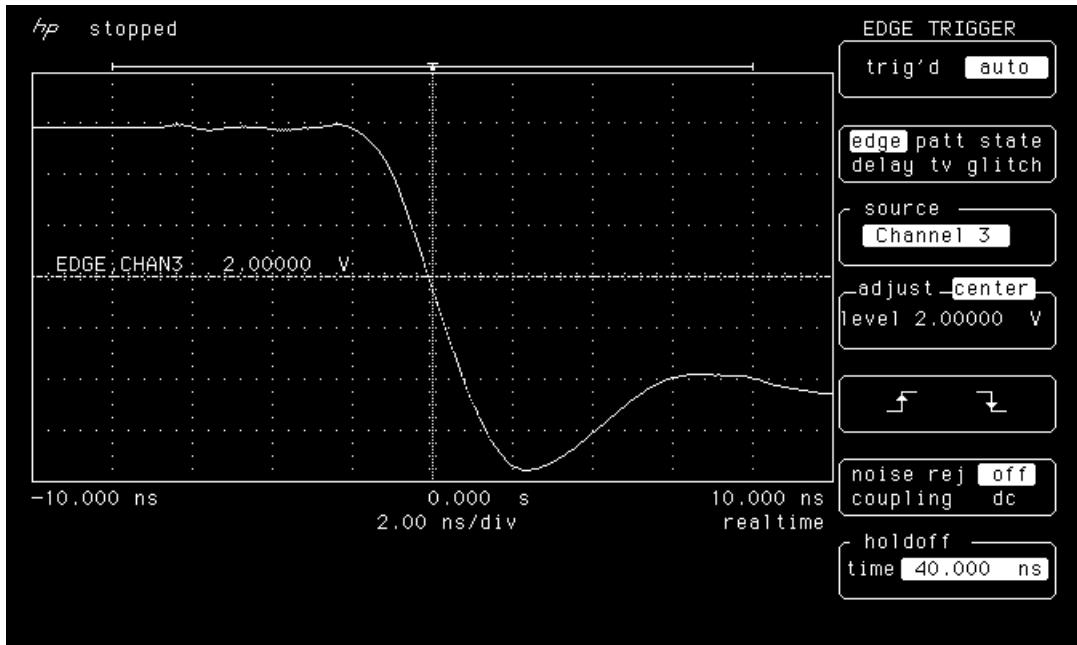


Figure 12a. Falling edge of LAN1704 pre-irradiation.

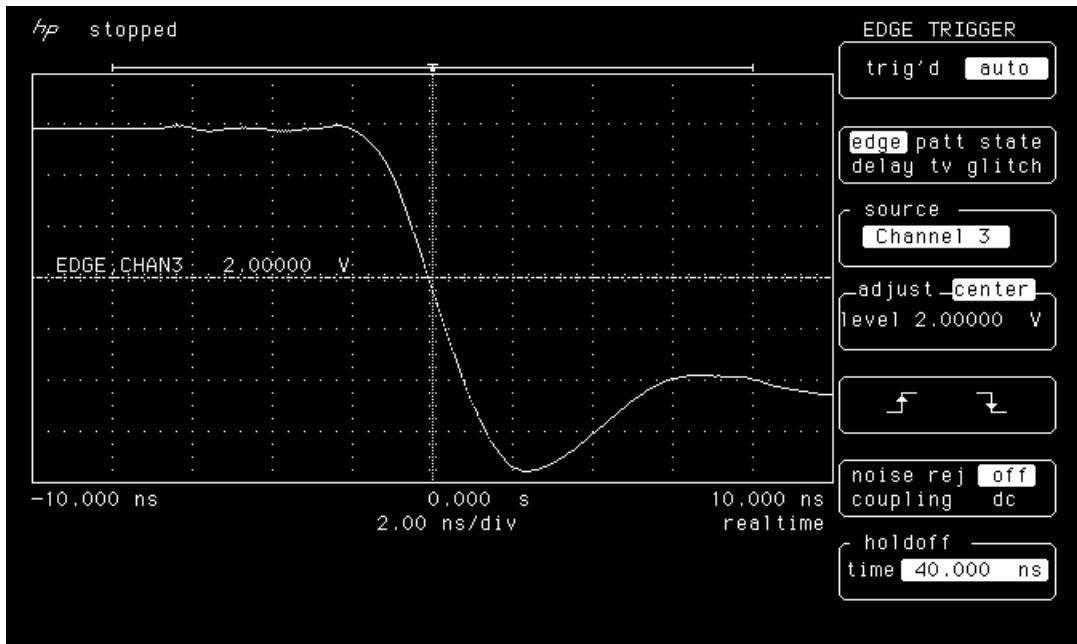


Figure 12b. Falling edge of LAN1704 post-100 krad(Si) irradiation

### **3.7 POWER-ON TRANSIENT CURRENT**

The power-on transient characteristics with respect to final total irradiation dose were measured. Figures 13-16 show the oscilloscope captures of power-on voltage and the current of pre-, post-100 krad(Si) irradiation of the DUTs. Note that in these Figures, C1 is the voltage, and C2 the current. The scale for current (C2) is always 100 mA/division. The results show that 100 krad(Si) irradiation at the dose rate of 12.95 krad(Si)/min didn't induce significant transient current in any case.

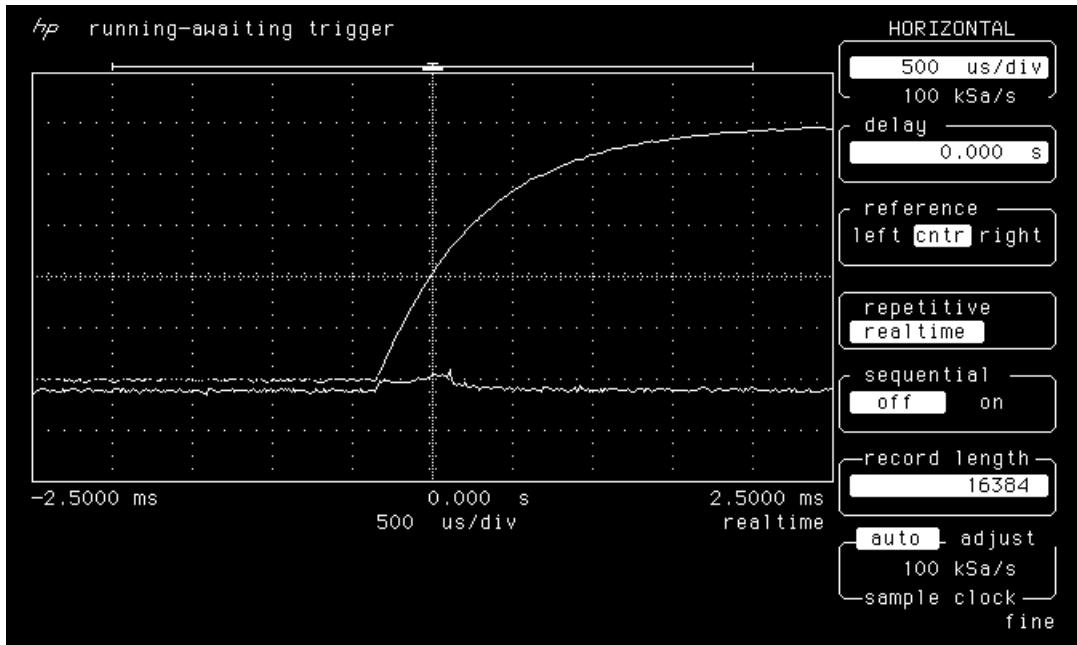


Figure 13a. Power-on transient current of LAN1701 pre-irradiation

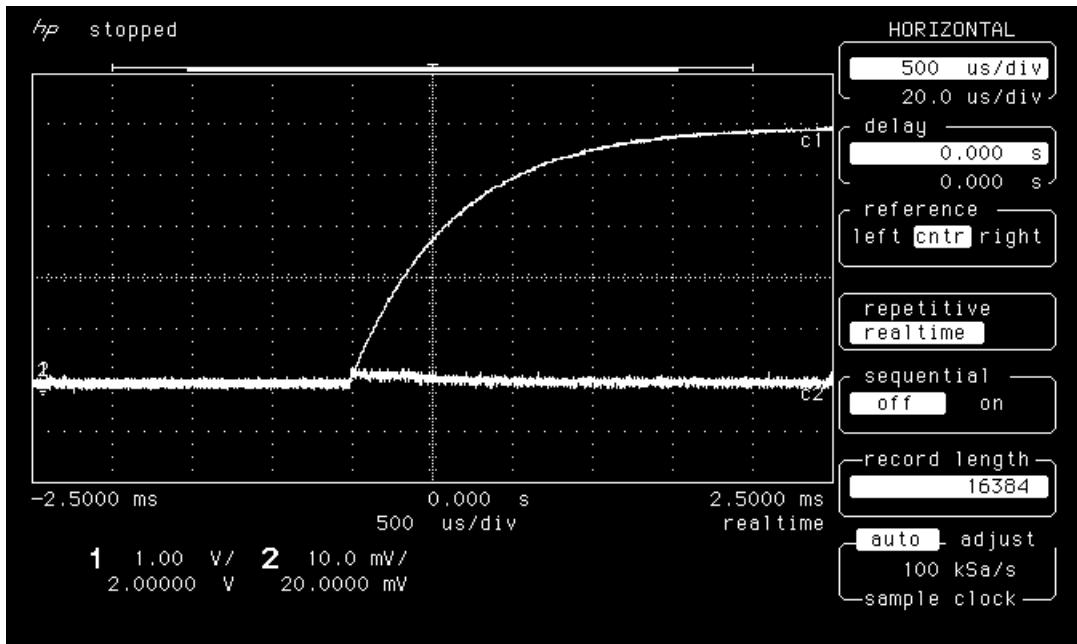


Figure 13b. Power-on transient current of LAN1701 post-100 krad(Si) irradiation

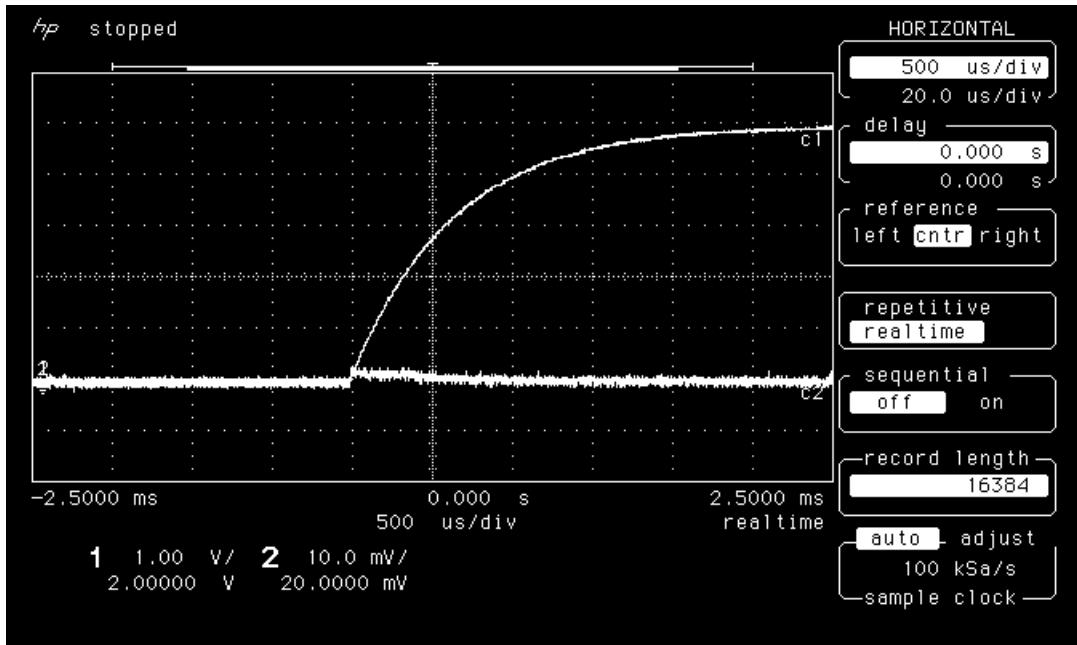


Figure 14a. Power-on transient current of LAN1702 pre-irradiation

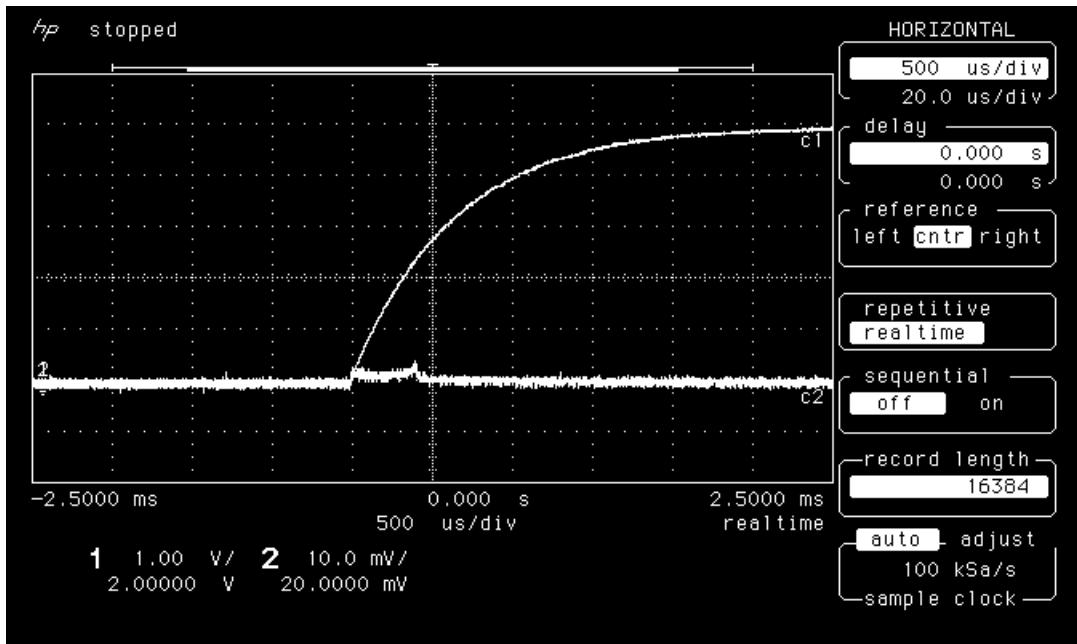


Figure 14b. Power-on transient current of LAN1702 post-100 krad(Si) irradiation

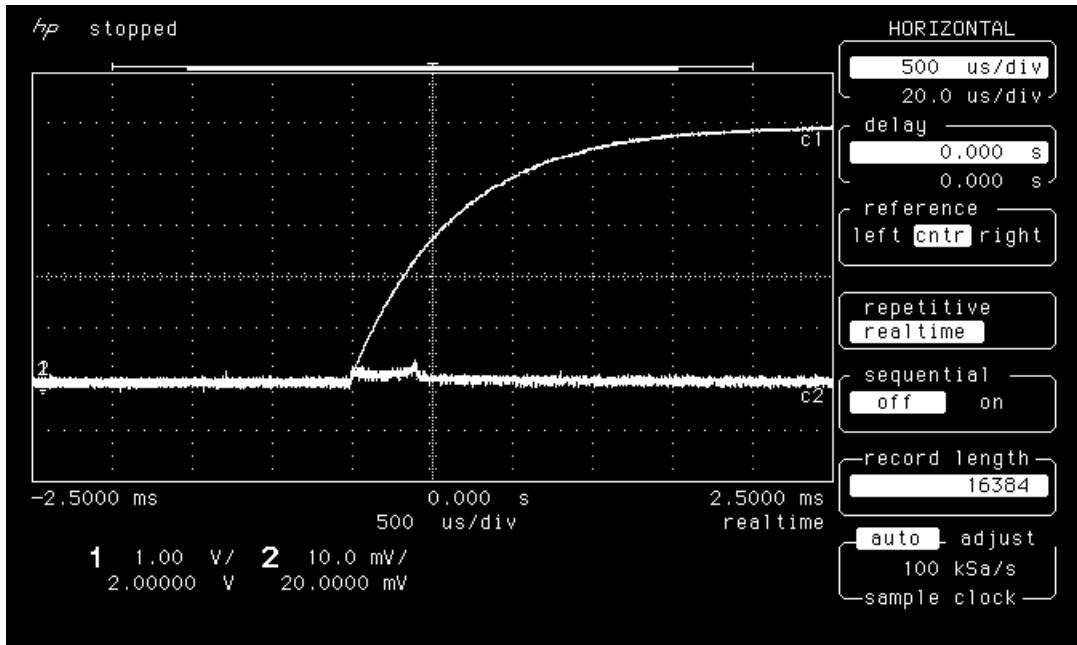


Figure 15a. Power-on transient current of LAN1703 pre-irradiation

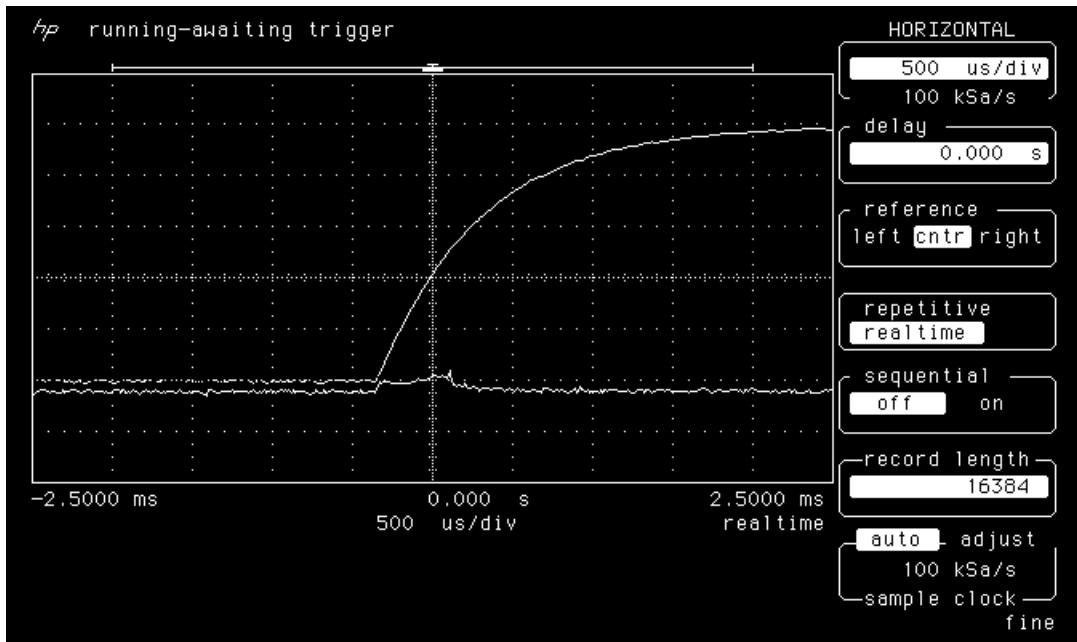


Figure 15b. Power-on transient current of LAN1703 post-100 krad(Si) irradiation

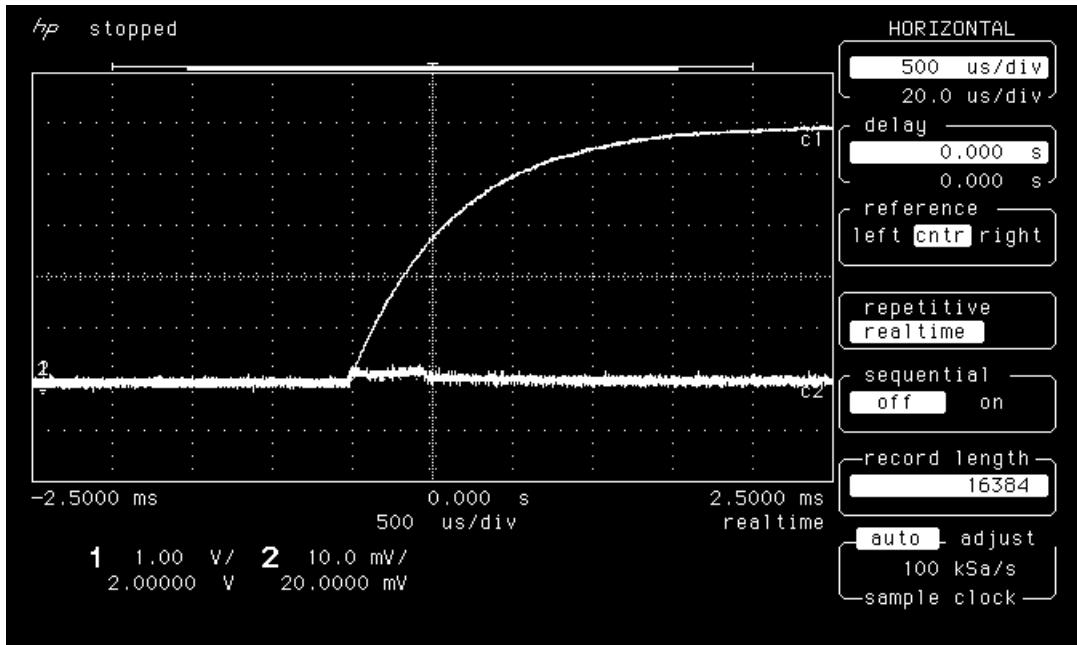


Figure 16a. Power-on transient current of LAN1704 pre-irradiation

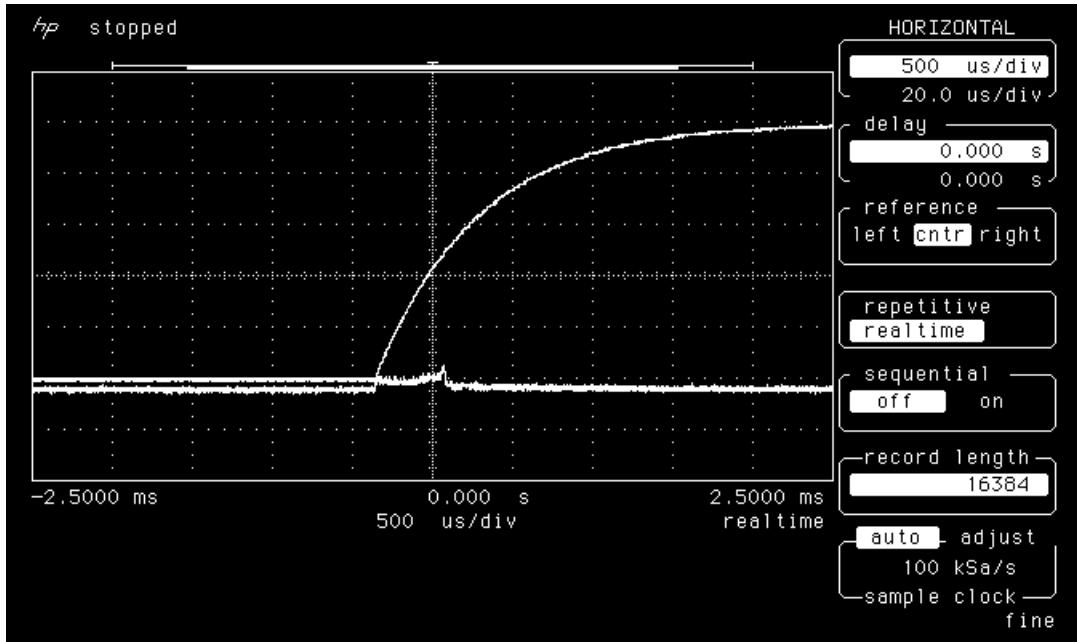


Figure 16b. Power-on transient current of LAN1704 post-100 krad(Si) irradiation